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## (54) Title of the invention: COMPOSITION OF STYRYL DERIVATIVE USING DEEP EUTECTIC SOLVENTS

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(86) International Application No Filing Date	:NA :NA	National Highway, Village Jhansla, Rajpura, Punjab - 140401, India Rajpura
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(61) Patent of Addition to Application Number Filing Date	:NA :NA	<ul> <li>(72)Name of Inventor:</li> <li>1)Dr. Rabindranath Jana</li> <li>Address of Applicant: Chitkara University Research &amp; Innovation</li> </ul>
(62) Divisional to Application Number Filing Date	:NA :NA	Network, Chitkara University, Chandigarh-Patiala National Highway, Village Jhansla, Rajpura, Punjab - 140401, India Rajpura

## (57) Abstract:

The present invention provides a composition comprising a styryl derivative and deep eutectic solvent wherein the interaction of deep eutectic solvent with styryl derivative, increases the solubility of styryl derivative dye and decreases the melting point

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